

## Supporting Information

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### 1. Materials and Measurements

**Materials:** PCE10-2F were synthesized in our previous work, PCE10-2F has a molecular weight of 58.8 kDa, Y5, Y6, L8-BO and PM6 were purchased from Derthon Optoelectronic Materials Science Technology Co LTD (Shenzhen, China). All reagents and commercially available compounds are used upon receipt.

### Measurements

Optical absorption spectra of the polymers were measured on a PerkinElmer model Lambda 900 UV-vis/near-IR spectrophotometer. Solution and solid-state absorption spectra were obtained from dilute ( $10^{-6}$  M) polymer solution in chloroform and from

thin films on glass substrate, respectively. Thin films were spin coated from 20 mg/mL solutions in chloroform.

The specimen for atomic force microscopy (AFM) measurements was prepared using the same procedures those for fabricating devices but without PDINO/Ag on top of the active layer. Transmission electron microscope (TEM) images were taken on a JEOL-2100F transmission electron microscope and an internal charge-coupled device (CCD) camera. The specimen for TEM measurement was prepared by spin casting the blend solution on ITO/PEDOT: PSS substrate, then floating the film on a water surface, and transferring to TEM grids.

The GIWAXS measurement was carried out at the PLS-II 6A U-SAXS beamline of the Pohang Accelerator Laboratory in Korea. The X-rays coming from the in-vacuum undulator (IVU) were monochromated (wavelength  $\lambda = 1.10994 \text{ \AA}$ ) using a double crystal monochromator and focused both horizontally and vertically (450 (H) x 60 (V)  $\mu\text{m}^2$  in FWHM @ the sample position) using K-B type mirrors. The grazing incidence wide-angle X-ray scattering (GIWAXS) sample stage was equipped with a 7-axis motorized stage for the fine alignment of the sample, and the incidence angles of the X-ray beam were set to be  $0.11^\circ$ - $0.13^\circ$  for the neat and blend films. The GIWAXS patterns were recorded with a 2D CCD detector (Rayonix SX165) and an X-ray irradiation time within 100 s, dependent on the saturation level of the detector. Diffraction angles were calibrated using a sucrose standard (monoclinic, P21,  $a=10.8631\text{\AA}$ ,  $b=8.7044\text{\AA}$ ,  $c=7.7624\text{\AA}$ , and  $b=102.938\text{\AA}$ ) and the sample-to-detector distance was  $\sim 231$  mm.

Solar cell characterization: The current density-voltage (*J-V*) curves of OSCs were measured in the glovebox with Keithley 2400, under AM 1.5G illumination at 100 mW  $\text{cm}^{-2}$  irradiation using an Enli SS-F5-3A solar simulator, and the light intensity was calibrated with a standard Si solar cell with KG2 filter (made by Enli Technology Co., Ltd., Taiwan, and calibrated report can be traced to NREL). The EQE spectrum was measured using a QE-R Solar Cell Spectral Response Measurement System (Enli Technology Co., Ltd., Taiwan).

## 2. Device fabrication

## 2.1 Opaque device fabrication

The device is fabricated with ITO/PEDOT:PSS/active layer/PDINO/Ag tradition structure. The ITO coated glass substrates were cleaned by ultrasound for 15 minutes in sequence in water/detergent, water, acetone and isopropanol, and then treated in ultraviolet-ozone for 1400 seconds. The PEDOT:PSS solution was spin-coated on top of the cleaned ITO-coated glass substrate and the PEDOT:PSS film thickness was approximately 25 nm. After annealing at 150 °C for 20 min, then the substrates were transferred into a glove box. For the solar cells based on NBG system, PCE10-2F or (PCE10-2F+DA, 1:0.2) with a concentration of 8 mg mL<sup>-1</sup> in CF were spun onto the PEDOT: PSS layers at 2500 rpm (60 nm) for 40 s form the front layer, Y6 and (Y6:Y5, 1:0.1) with a concentration of 10 mg mL<sup>-1</sup> in CF, and 1,8-diodooctane (DIO) and CN was added (volume ratio 0.25% and 0.25%, respectively). then spun onto the PCE10-2F layers at 2300 rpm (40nm) for 40 s. After annealing at 100 °C for 10 min. For the solar cells based on WBG system, The PM6: acceptors active layers (D:A = 1:1.2) weight ratio for binary, The DA:PM6: L8-BO:Y5 active layers (D:A = 0.25:1:1.1:0.1) weight ratio for quaternary, were then spin-coated from 16.5 mg/mL chloroform solution with 0.3 vol.% 1,8-diodooctane (DIO) for PM6:L8-BO binary blend and DA:PM6: L8-BO:Y5 quaternary active layers, at 3000 rpm for the 30s to form an active layer of around 100 nm. The PDINO was dissolved in methanol at 3 mg mL<sup>-1</sup> and spin-coated on active layer at 3000 rpm for 30s. Finally, 90-nanometer thick Ag layers were deposited on the active layer under high vacuum of ~3x10<sup>-4</sup>Pa. The overlapping area of cathode and anode was 4 square millimeters. J-V curves of devices based on polymer doner: Y6 were measured under the standard AM 1.5G spectrum of 100 MW cm<sup>-2</sup>.

**Semitransparent device fabrication** was fabricated by following the same procedure. 15nm or 25nm thickness Ag and layers were deposited on the active layer under high vacuum of ~3x10<sup>-4</sup>Pa. Then, MoO<sub>3</sub> (35 nm) were evaporated onto the surface of Ag. The overlapping area of cathode and anode was 4 square millimeters. J-V curves of ST-OSC devices were measured under the standard AM 1.5G spectrum of 100 MW cm<sup>-2</sup>.

Electroluminescence (EL) quantum efficiency (EQE<sub>EL</sub>) measurements were performed by applying external voltage sources through the devices from 1V to 4V. A

Keithley 2400 SourceMeter was used for supplying voltages and recording injected current, and a Keithley 485 picoammeter was used for measuring the emitted light intensity.

### 3. Optical Characterization

The average visible transmittance (AVT) is calculated using

$$VLT = \frac{\int T(\lambda)P(\lambda)S(\lambda)d(\lambda)}{\int P(\lambda)S(\lambda)d(\lambda)} \quad VLT = \frac{\int T(\lambda)P(\lambda)S(\lambda)d(\lambda)}{\int P(\lambda)S(\lambda)d(\lambda)}$$

$$AVT = \frac{\int T(\lambda)V(\lambda)S(\lambda)d(\lambda)}{\int P(\lambda)S(\lambda)d(\lambda)} \quad (\text{Eq. S1})$$

where  $\lambda$  is the wavelength, T is the transmission, V is the normalized photopic spectral response of the eye, and S is the solar photon flux (AM1.5G). It is estimated by taking the average of the transparency of the devices in the visible region (380-740 nm) based on the photonic response of the human eye.

Infrared photon rejection rate (IRR) is defined as:

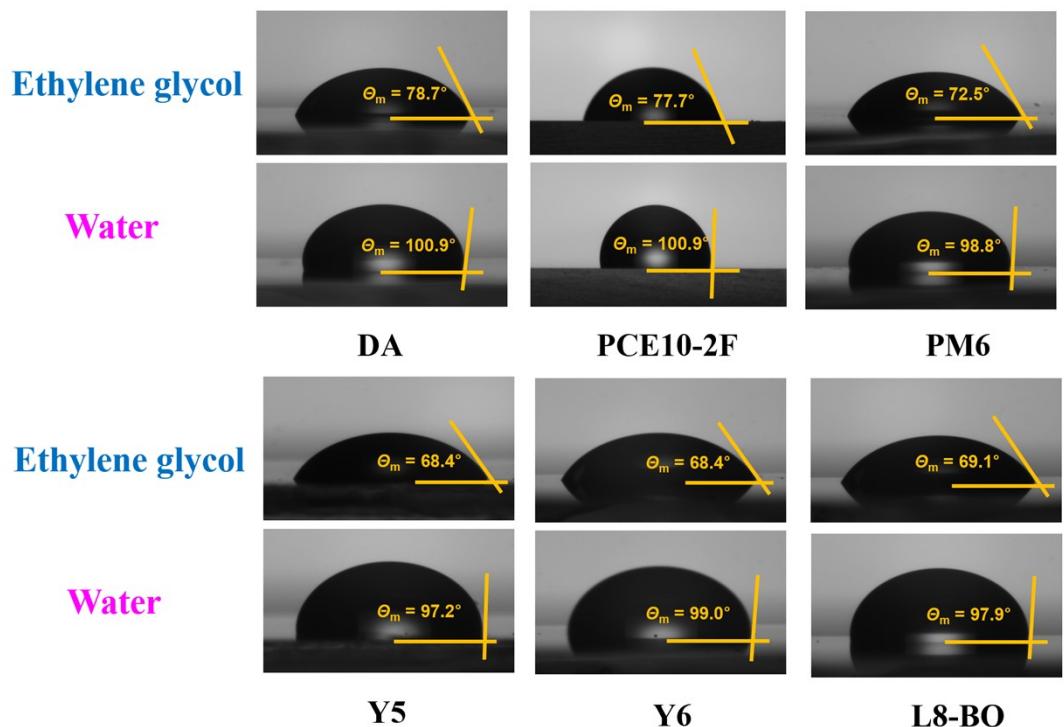
$$\text{IRR} = 1 - \frac{\int T(\lambda)S(\lambda)d\lambda}{\int S(\lambda)d\lambda}$$

where T is the transmittance, S is the solar photon flux, and  $\lambda$  is the wavelength.

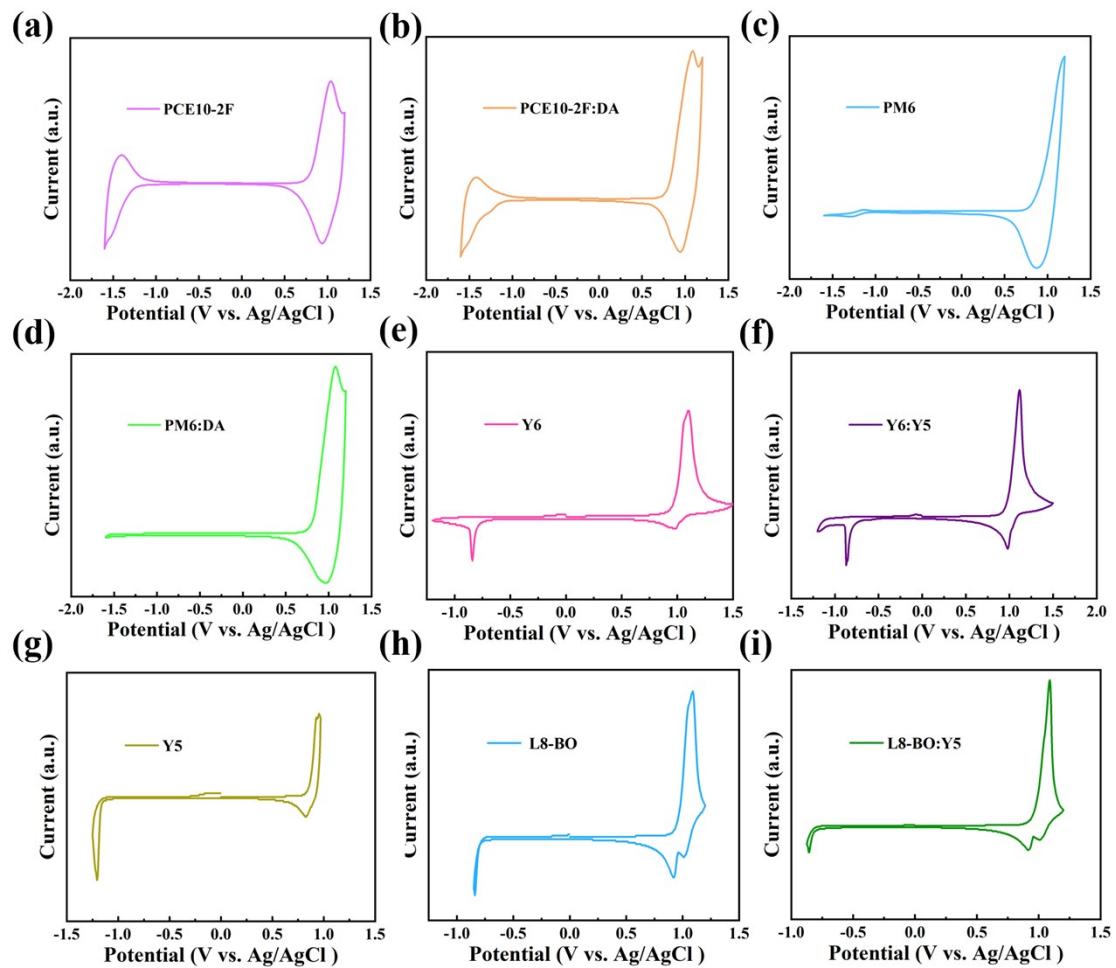
All the photographs are taken by Apple iPhone13 Pro.

### 4. Thermal Insulation Performance Test

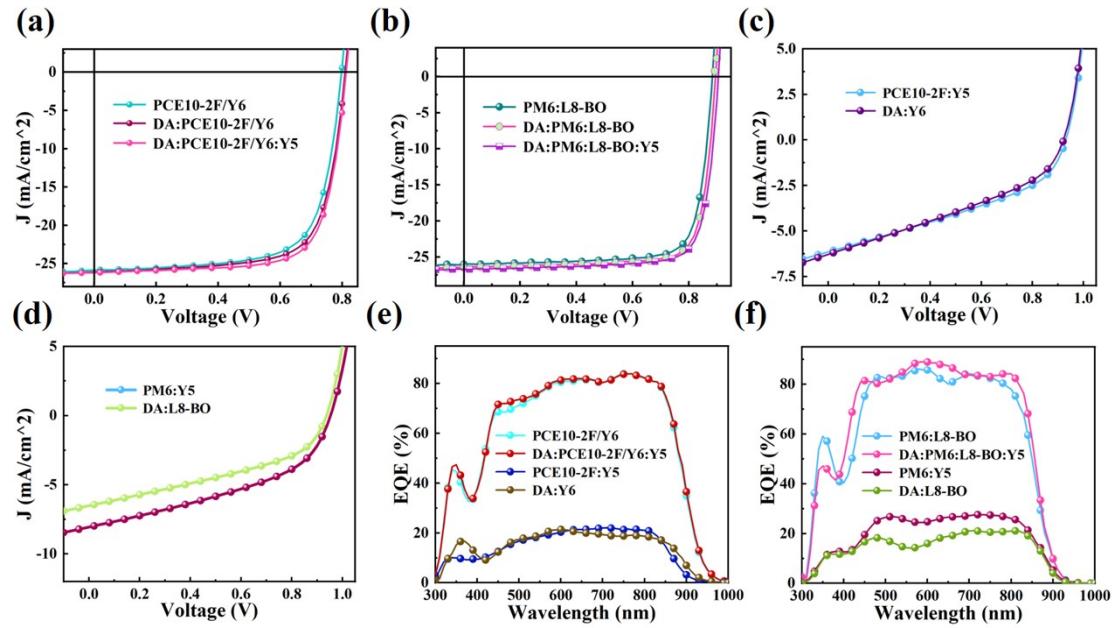
The model of the infrared heater is Philips PAR38E, the power is 150W, and the irradiation distance is 25cm.



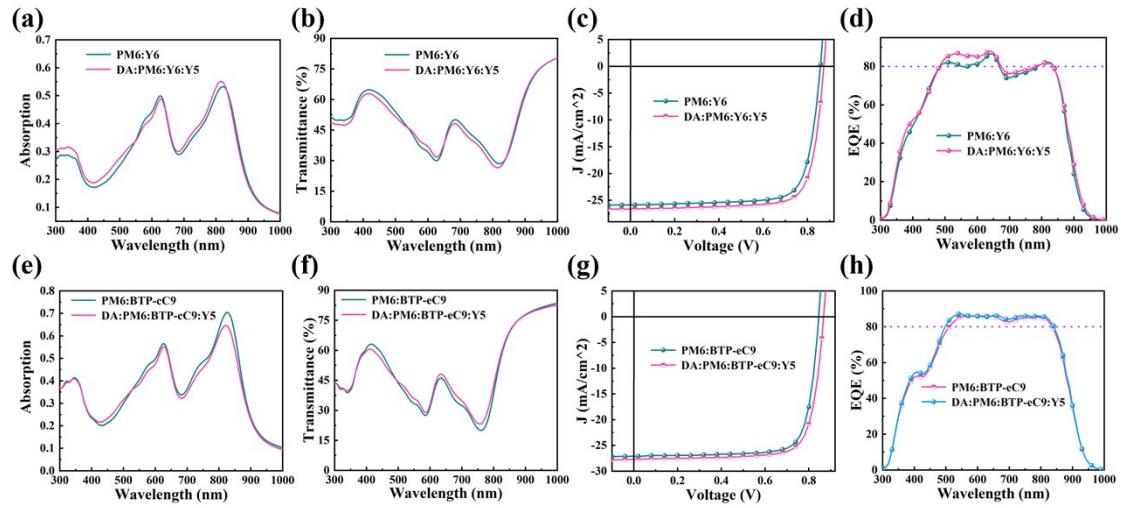
**Figure S1.** Contact angle images of DA, PCE10-2F, PM6, Y5, Y6 and L8-BO films with water and ethylene glycol droplet on top.



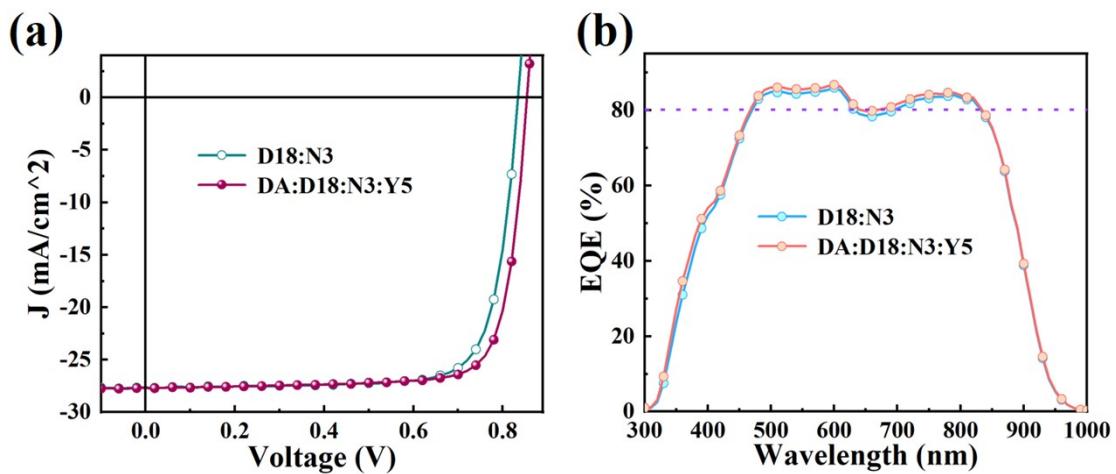
**Figure S2.** (a-i) CV curves of PCE10-2F, PCE10-2F:DA, PM6, PM6:DA, Y6, Y5, Y6:Y5, L8-BO and L8-BO:Y5 blend films.



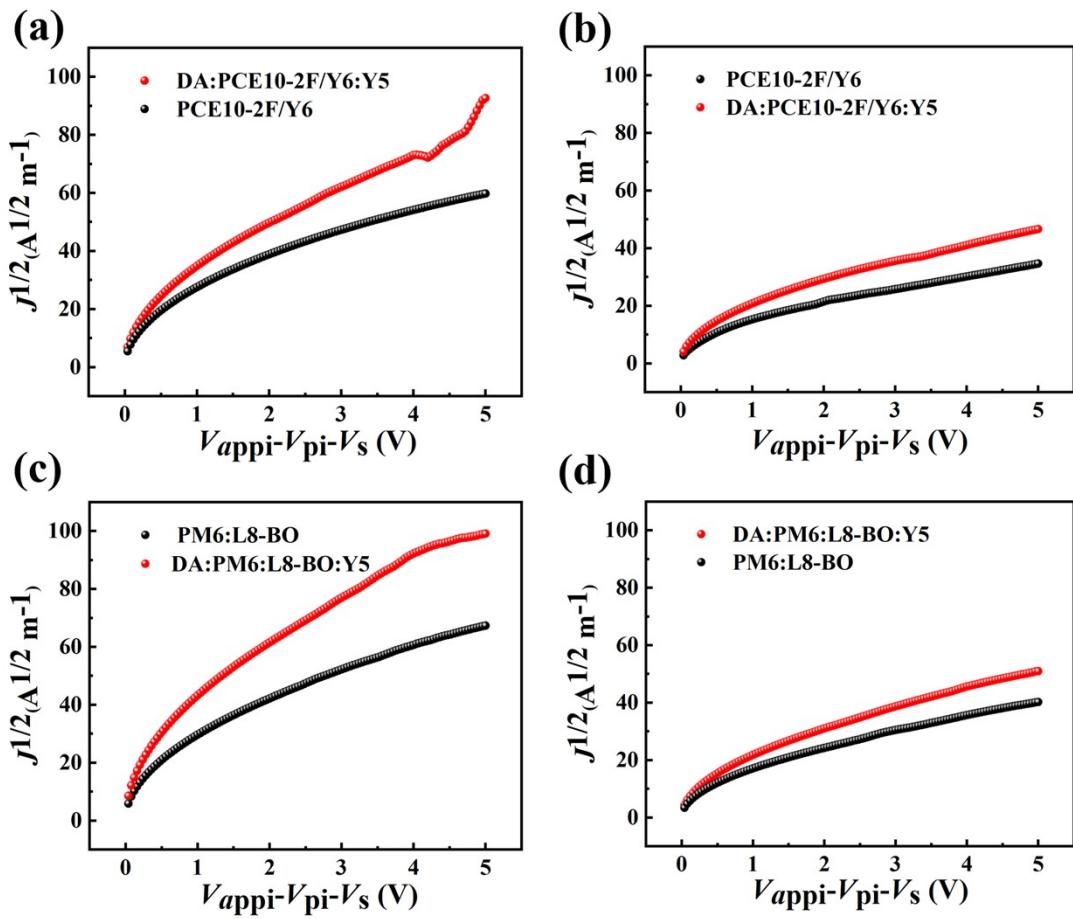
**Figure S3.** (a) J-V curves of PCE10-2F/Y6, DA: PCE10-2F/Y6 and DA: PCE10-2F/Y6:Y5-based OSC devices. (b) J-V curves of PM6:L8-BO, DA PM6:L8-BO and DA: PM6:L8-BO:Y5-based OSC devices. (c) J-V curves of PCE10-2F:Y5, DA:Y6-based OSC devices. (d) J-V curves of PM6:Y5, DA:L8-BO-based OSC devices. (e) EQE curves of PCE10-2F/Y6, DA: PCE10-2F/Y6:Y5, PCE10-2F:Y5 and DA:Y6-based OSC devices. (f) EQE curves of PM6:L8-BO, DA: PM6:L8-BO:Y5, PM6:Y5 and DA:L8-BO -based OSC devices.



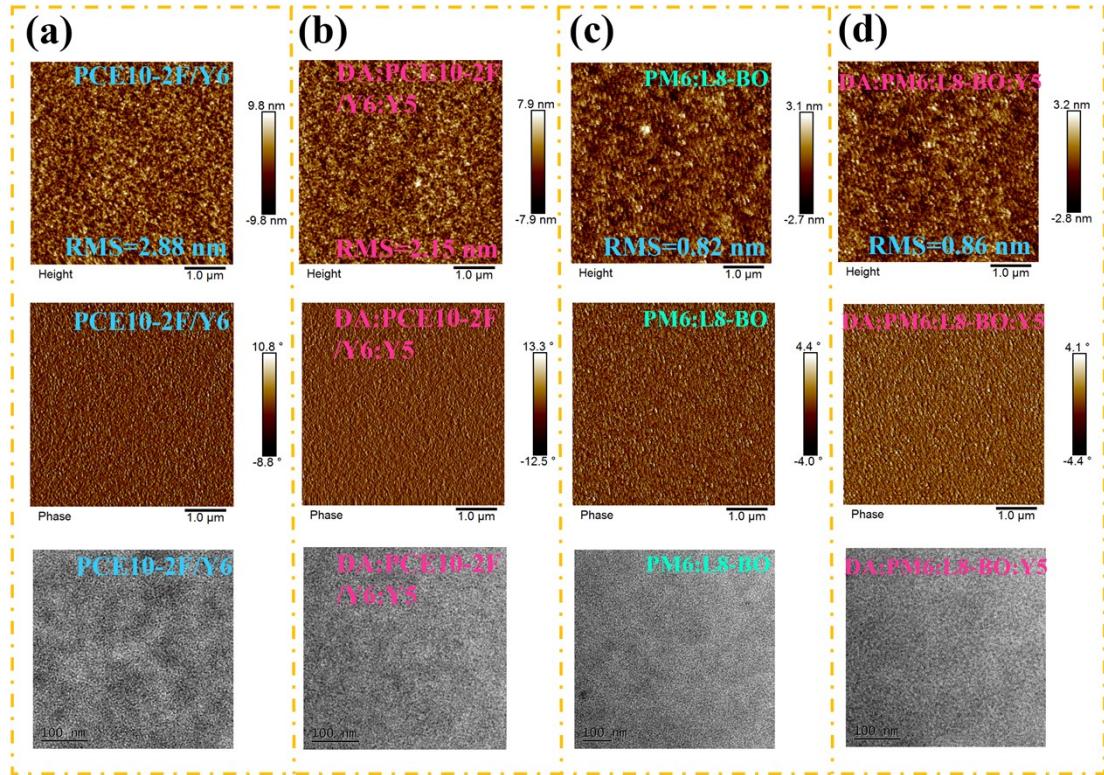
**Figure S4.** (a) Absorption spectra and (b) transmittance spectra of PM6:Y6, DA:PM6:Y6:Y5 blend films. (c)  $J$ - $V$  and (d) EQE curves of PM6:Y6 and DA:PM6:Y6:Y5-based OSC devices. (e) Absorption spectra and (f) transmittance spectra of PM6:BTP-eC9, DA:PM6:BTP-eC9:Y5 blend films. (g)  $J$ - $V$  and (h) EQE curves of PM6:BTP-eC9, DA:PM6:BTP-eC9:Y5-based OSC devices.



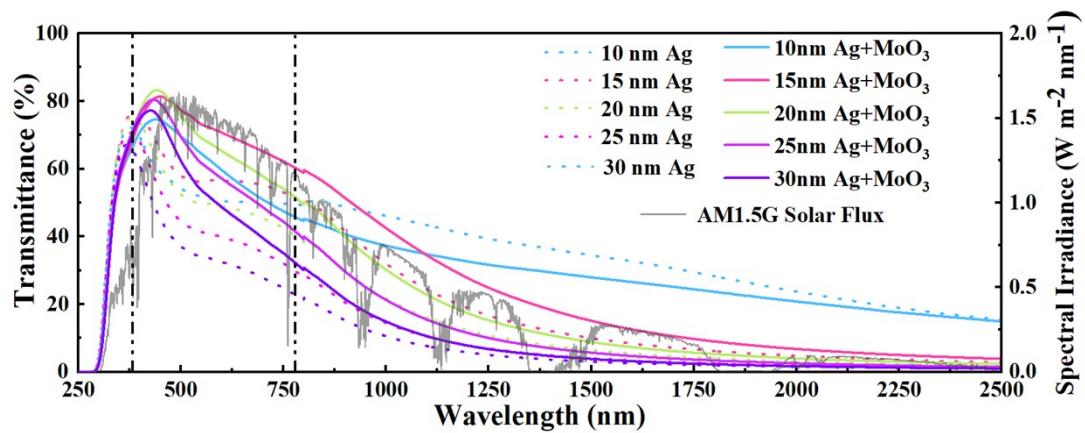
**Figure S5.** (a)  $J$ - $V$  and (b) EQE curves of D18/N3, DA: D18/N3:Y5-based OSC devices.



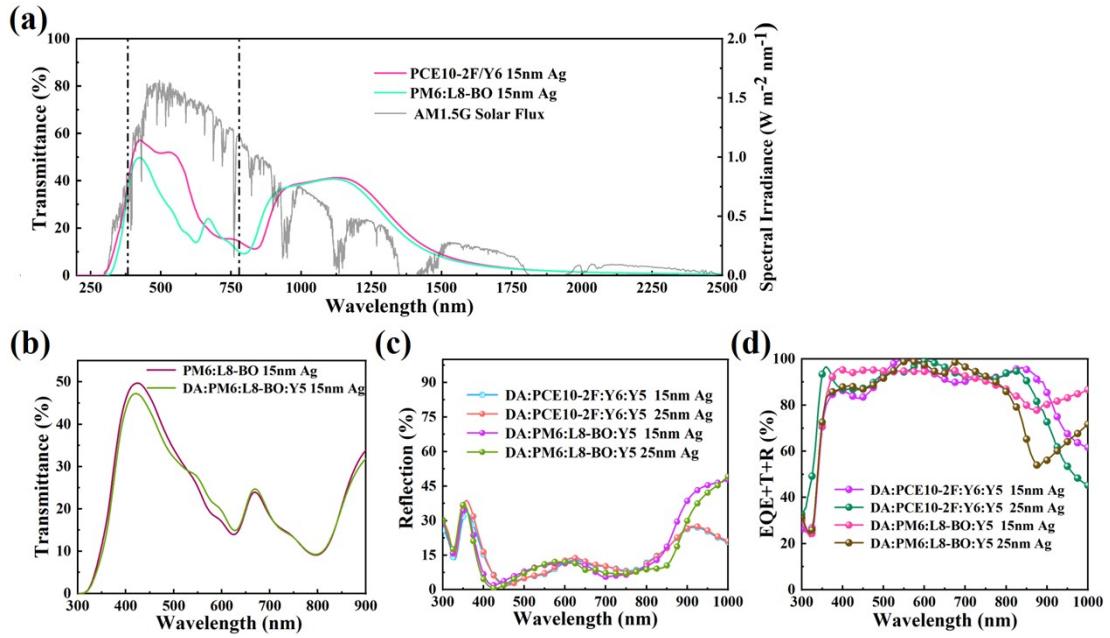
**Figure S6.**  $J^{1/2}$ –V plots of hole-only devices and  $J^{1/2}$ –V plots of electron-only devices (in dark).



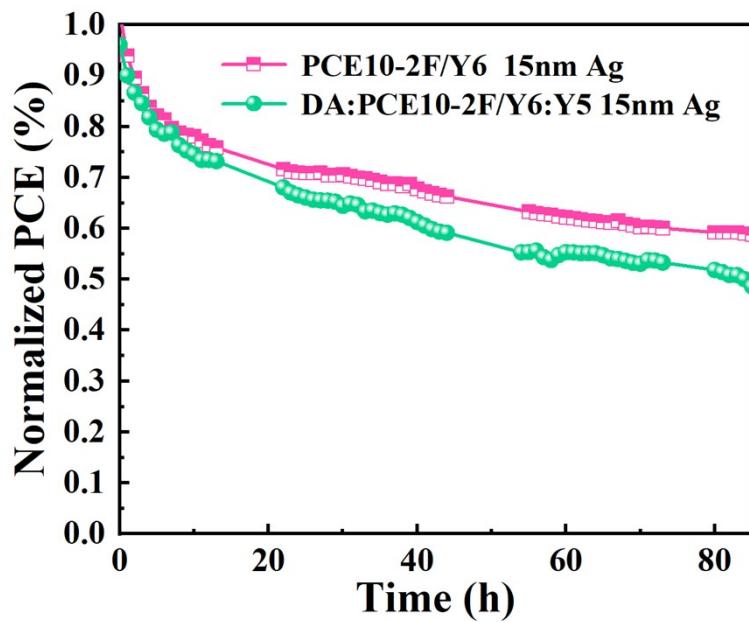
**Figure S7.** AFM and TEM images of optimized WBG system blend films.



**Figure S8.** (a) Transmittance of 10 nm, 15 nm, 20 nm, 25 nm, 30 nm Ag thickness back electrode (ITO/Glass/PDINN/Ag/with or without  $\text{MoO}_3$ ).



**Figure S9.** (a-b) Transmittance spectra of PCE10-2F/Y6, PM6:L8-BO and DA:PM6:L8-BO:Y5-based ST-OSCs. (c-d) The reflectance spectra and photon balance check spectra ( $\text{EQE}(\lambda)\% + \text{T}(\lambda)\% + \text{R}(\lambda)\%$ ) spectra of ST-OSCs.



**Figure S10.** Stability of ST-OSCs under AM 1.5G 100 mW cm<sup>-2</sup> simulated sunlight continuous illumination with 1h intervals for data collection.

**Table S1.** Photovoltaic performance of binary and multi-component OSCs with different DA and Y5 ratio.

Device	D/A	$V_{oc}$ (V)	$J_{sc}$ (mA/cm <sup>2</sup> )	FF (%)	PCE (%)
<b>PCE10-2F/Y6</b>	60/40nm	0.796	25.87	70.56	14.55
<b>PCE10-2F/Y5</b>	60/40nm	0.930	6.14	38.20	2.17
<b>DA/Y6</b>	60/40nm	0.921	6.28	35.62	2.05
<b>DA:PCE10-2F/Y6</b>	0.1:1, 60/40nm	0.801	25.92	70.70	14.68
	0.2:1, 60/40nm	0.808	26.13	71.40	15.11
	0.3:1, 60/40nm	0.811	25.77	69.23	14.47
<b>PCE10-2F/Y6:Y5</b>	60/40nm, 1:0.1	0.803	26.04	70.98	14.84
<b>DA:PCE10-2F/Y6:Y5</b>	0.2:1,60/40nm,1:0.05	0.808	25.99	73.88	15.51
	0.2:1,60/40nm, 1:0.1	0.812	26.20	73.22	15.57
	0.2:1,60/40nm, 1:0.15	0.816	25.37	70.42	14.58
<b>PM6:L8-BO</b>	1:1.2	0.880	25.96	78.79	18.01
<b>PM6:Y5</b>	1:1.2	0.952	8.05	42.76	3.27
<b>DA:L8-BO</b>	1:1.2	0.937	6.51	40.54	2.46
<b>DA:PM6:L8-BO</b>	0.15:1:1.2	0.888	26.14	79.89	18.54
	0.25:1:1.2	0.892	26.44	79.41	18.74
	0.35:1:1.2	0.895	25.79	78.34	18.08
<b>PM6:L8-BO:Y5</b>	1:1.2:0.1	0.888	26.11	79.08	18.34
<b>DA:PM6:L8-BO:Y5</b>	0.25:1:1.2:0.1	0.903	26.69	79.18	19.09

**Table S2.** Operating characteristics of opaque devices under simulated AM 1.5G, 100 mW cm<sup>-2</sup> illumination.

Devices	D/A	$V_{OC}$ (V)	$J_{SC}$	AVT				active layer (%)
			$J_{SC}$ (mA/ cm <sup>2</sup> )	$cal^{(a)}$ (mA/ cm <sup>2</sup> )	FF (%)	PCE <sup>(b)</sup> (%)		
<b>PM6:Y6</b>	1:1.2	0.859	25.86	25.09	77.05	17.12(16.93)	38.84	
<b>DA: PM6:Y6:Y5</b>	0.25:1:1.2:0.1	0.874	26.63	25.84	77.62	18.08(17.79)	40.40	
<b>PM6:BTP-eC9</b>	1:1.2	0.843	27.11	26.20	78.74	18.00(17.83)	36.11	
<b>DA: PM6:BTP-eC9:Y5</b>	0.25:1:1.2:0.1	0.865	27.71	26.59	78.11	18.72(18.59)	37.82	
<b>D18:N3</b>	60 nm/45 nm	0.832	27.66	26.37	78.14	17.98(17.69)	35.23	
<b>DA:D18:N3:Y5</b>	0.2:1,60nm/1:0.1,45nm	0.853	27.70	26.45	79.67	18.80(18.66)	36.07	

**Table S3.** Hole and electron mobilities of PCE10-2F/Y6, DA:PCE10-2F/Y6:Y5, PM6:L8-BO and DA:PM6:L8-BO:Y5 devices in the dark.

Device	$\mu_h(\text{cm}^2 \text{ V}^{-1} \text{ s}^{-1})$	$\mu_e(\text{cm}^2 \text{ V}^{-1} \text{ s}^{-1})$	$\mu_h/\mu_e$
PCE10-2F/Y6	$8.685 \times 10^{-4}$	$8.155 \times 10^{-4}$	1.064
DA:PCE10-2F/Y6:Y5	$9.008 \times 10^{-4}$	$8.805 \times 10^{-4}$	1.023
PM6:L8-BO	$8.945 \times 10^{-4}$	$8.559 \times 10^{-4}$	1.045
DA:PM6:L8-BO:Y5	$9.145 \times 10^{-4}$	$8.948 \times 10^{-4}$	1.022

**Table S4.** Summarized parameters for the ordering structures of neat films and blend films.

Film	Out-of-Plane				In-Plane			
	$\pi$ - $\pi$ stacking cell axis (010)				Unit cell long axis (100)			
	q ( $\text{\AA}^{-1}$ )	d-spacing ( $\text{\AA}$ )	FWHM ( $\text{\AA}^{-1}$ )	Coherence length ( $\text{\AA}$ )	q ( $\text{\AA}^{-1}$ )	d-spacing ( $\text{\AA}$ )	FWHM ( $\text{\AA}^{-1}$ )	Coherence length ( $\text{\AA}$ )
PCE10-2F	1.606	3.910	0.278	20.5	0.262	24	0.1	56.3
PCE10-2F:DA	1.631	3.850	0.43	23.5	0.270	23.3	0.083	68.5
Y6	1.731	3.627	0.155	36.8	0.273	23	0.07	80.8
Y6:Y5	1.738	3.613	0.176	32.5	0.276	22.7	0.082	69.4
PCE10-2F/Y6	1.691	3.714	0.144	39.8	0.298	21.1	0.041	136.8
DA:PCE10-2F/Y6:Y5	1.637	3.562	0.250	22.9	0.301	20.9	0.057	70.4
PM6	1.653	3.799	0.294	19.4	0.285	22.0	0.089	63.3
PM6:DA	1.721	3.649	0.187	30.6	0.299	21	0.054	104.4
PM6:L8-BO	1.702	3.690	0.164	34.8	0.270	23.3	0.066	85.6
DA:PM6:L8-BO:Y5	1.713	3.666	0.188	30.4	0.272	23.1	0.069	82.5

**Table S5.** Detailed parameters of silver electrodes with different thickness.

Electrode	AVT (%)	IRR (%)	Sheet resistance ( $\Omega$ )
<b>100nm Ag</b>	0	100	1.58
<b>10nm Ag</b>	63.66	65.22	6.89
<b>15nm Ag</b>	73.16	64.62	2.74
<b>20nm Ag</b>	69.10	73.78	2.50
<b>25nm Ag</b>	61.71	80.81	2.32
<b>30nm Ag</b>	53.77	86.10	1.96

**Table S6.** Detailed parameter on state-of-the-art ST-OSC devices without complex optical engineering reported in the literatures.

Acytive layer	PCE (%)	AVT (%)	LUE (%)	Reference
DA:PCE10-2F/Y6:Y5	12.95	31.35	4.06	This work
DA:PCE10-2F/Y6:Y5	11.18	45.61	5.10	This work
DA:PM6:L8-BO:Y5	13.56	25.08	3.44	This work
PM6:BTP-eC9:L8-BO	11.44	46.79	5.35	1
PCE-10:A078	10.8	45.7	5.0	2
PBDB-TF:L8-BO:BTP-eC9	12.95	38.67	5.0	3
PTB7-Th: H3	8.38	50.9	4.27	4
PTB7-Th: FOIC: PC <sub>71</sub> BM	8.66	50.04	4.33	5
PL-Cl: F8IC	11.0	35.0	3.85	6
PTB7-Th: FOIC	10.3	37.4	3.85	7
PBT1-C-2Cl: Y6	9.1	40.1	3.65	8
PCE-10: BT-CIC: TT-FIC	8.0	44.2	3.54	9
PTB7-Th: IEICO-4Cl	8.38	25.7	2.15	10
PTB7-Th: IUIC	10.2	31	3.16	11
PCE-10: BT-CIC	7.1	43	3.05	12
PTB7-Th: ATT-2	7.7	37	2.85	13
PBDB-T: ITIC	7.3	25.2	1.84	14
PTB7-Th: IHIC	9.77	36	3.52	15
PTB7-Th: COi8DFIC: IEICO-4F	8.23	20.78	1.71	16

PBDTTT-ET: IEICO	6.8	25.1	1.71	17
PTB7-Th: PBT1-S: PC71BM	9.2	20	1.84	18
PBDB-T-2F: Y6	12.88	25.6	3.30	19
PTB7-Th: ACS8	11.1	28.6	3.17	20
PTB7-Th: BDTThIT-4F: IEICO-4F	9.40	24.6	2.31	21
PTB7-Th: IEICO-4F	9.06	27.1	2.46	22
PTB7-Th: IEICO-4F	10.03	34.2	3.43	23
PBDB-T: Y14	12.67	23.69	3.00	24
PBFTT: IT-4Cl	9.1	27.6	2.51	25
PFTzTT3TC: ITIC	6.43	26.77	1.72	26
PBN-S: IT-4F	9.83	32	3.15	27
PTB7-Th: IEICO-4F	10.83	29.5	3.19	28
PDTP-DFBT: FOIC	4.2	52	2.18	29
J71:PTB7-Th: IHIC	9.3	21.4	2.01	30
DTG-IW: PTB7-Th	6.19	50.4	3.12	31
PM6: Y6: PC71BM	10.2	28.6	2.92	32
PBDB-TF: Y6: BTTPC	13.1	22.35	2.93	33
PBDB-TF: Y6: DTNIF	13.49	22.58	3.05	34
PBDB-TF: Y6: PC71BM	13	21.4	2.78	35
PCE10: ICBA:Y8	10.46	26.56	2.78	36
D18-Cl: Y6-1O: Y6	13.02	20.2	2.63	37

PCE10-2Cl: IT-4F	8.25	33	2.72	38
PM2: Y6-BO	5.9	43.3	2.55	39
PM6: Y6: DIBC	14.00	21.60	3.02	40
PM6: Y6	9.7	42.82	4.15	41
PCE10-BDT2F-0.8: Y6	10.85	41.08	4.46	42
PTB7-Th: ATT-9	9.37	35.5	3.33	43
PM6-Ir1: BTP-eC9: PC71BM	14.09	20.44	2.82	44

**Table S7.** Detailed parameter on state-of-the-art multifunctional ST-OSC devices reported in the literatures.

Device structure	PCE (%)	AVT (%)	LUE (%)	IRR (%)	Reference
ITO/PEDOT:PSS/active layer/PDINN/ Ag /MoO <sub>3</sub>	12.83	31.35	4.02	90	45
ITO/PEDOT:PSS-TA/active layer/Bis-FIMG/ultrathin Ag /DBR	11.18	32.07	3.58	90	46
ITO/PEDOT:PSS/active layer/PDINN/Ag	9.37	35.5	3.33	84.3	47
ITO/PEDOT:PSS/active layer/PFN-Br/Ag /DBR	12.3	23.45	2.88	90	48
ITO/PEDOT:PSS/active layer/PFN-Br/Ag /DBR	8.4	22.8	1.92	83.1	49
ITO/PEDOT:PSS/active layer/PFN-Br/Ag /DBR	7.3	29.5	2.15	93.1	55

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